Scanning Hall Probe Microscopy Analysis of Critical Current Density in Superconducting Materials

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Realistic applications for superconductors abound in the realms of electronics, mechanics, and power transport. However, superconductivity relies on the microscopic properties of a material to provide the macroscopic benefits of zero resistance and incredibly high current loads. The production of superconducting wires or tapes requires that the microscopic structures of the material are carefully controlled so that current density is maximized. While the transport current density can be easily measured through four-probe testing or other simpler means, to gain an understanding of the localized critical current density or its distribution these methods prove inadequate or impractical. It is imperative that this data is obtained so that the microscopic structures that seem to limit or improve critical current can be identified and removed or replicated. The use of Hall probe microscopy allowed for the rapid analysis of current density within several superconducting samples through the measurement of their produced magnetic fields. In addition, by inducing current within the superconducting samples, the measured current densities were the critical values at the specified magnetic field strength and temperature. The inverse problem of Biot-Savart law, converting the magnetic field data into a current distribution, has been solved with a sheet current approximation in order to calculate the critical current density distribution solely from the perpendicular component of the 2-D magnetic field emitted from the sample.







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Improving Current Density Analysis

The mass production of superconducting wires and tapes will require the ability to produce:

- Kilometers of superconducting material \bullet
- Microscopic structures which generate superconductivity

However, the 4-probe method that is traditionally used to measure superconductors' performance has no spatial resolution



Hall probe microscopy can rapidly provide high resolution critical current density (J_c) distribution images and data for large samples of superconducting material to allow for the identification of performance limiting obstacles

Current Technologies

The 4-probe method can provide a measurement of the transport J_c

- This is a measurement of the maximum current density between two points
- This measurement cannot determine the location between those two points where the current is limited



Niobium Titanium is one of the most widely used superconducting materials:

- However, there is still room to increase its critical current (I_c) by optimizing processing
- Internal current distribution data can be used to identify the current limiting or enhancing mechanisms

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